EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	3	"6306564".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 18:31
L2	3250	(substrate or semiconductor or wafer or semi \$1 conductor) same (rotat\$3 or spin\$4) and (fluid or liquid or solution) near10 ((high near2 pressure) or (pressure adj (vessel or chamber))) and (spray\$3 or nozzle or discharg\$3 or dispos\$3)	US-PGPUB; USPAT; USOOR; EPO; JPO; DERWENT	OR	ON	2008/05/09 18:39
L3	1180	(substrate or semiconductor or wafer or semi \$1conductor) same (rotat\$3 or spin\$4) and (fluid or liquid or solution) near10 ((high near2 pressure) or (pressure adj (vessel or chamber))) and (spray\$3 or nozzle or dispos\$3) and (chamber or tank) same (hold\$3 or plate)	US-PCPUB; USPAT; USOCR; EPO; JPO; DEPWENT	OR	ON	2008/05/09

L4	643	(substrate or semiconductor or wafer or semi \$1 conductor) same (rotat\$3 or spin\$4) and (fluid or liquid or solution) near10 ((high near2 pressure) or (pressure adj (vessel or chamber))) and (spray\$3 or nozzle or dispos\$3) same (chamber or tank) same (hold\$3 or plate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 18:40
L5	34	(fluid or liquid or solution) near10 ((high near2 pressure) or (pressure adj (vessel or chamber))) and (horiztonal\$4 or side or lateral or swirl\$3 or spin\$4 or flowing) with (spray \$3 or nozzle or discharg\$3 or dispos \$3) same (chamber or tank) same (hold \$3 or plate) same (substrate or semiconductor or wafer or semi \$1conductor) same (rotat\$3 or spin\$4)	US PGPUB; USPAT; USOCR; EPO; JPO; DEFWENT	OR	ON	2008/05/09 18:40
L6	34	(fluid or liquid or solution) near10 ((high near2 pressure) or (pressure adj (vessel or chamber))) and (horiztonal\$4 or side or lateral or swirl\$3 or spin\$4 or flowing) with (spray \$3 or nozzle or discharg\$3 or dispos	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OS	2008/05/09 18:40

	***************************************	\$3) same (chamber or tank) same (hold \$3 or plate) same (substrate or semiconductor or wafer or semi \$1conductor) same (rotat\$3 or spin\$4)			***************************************	
L7	9	L6 and "134".clas.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 18:40
L8	1130	134/200	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 19:07
L9	46	iwata adj tomomi.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 19:08
L10	81	saito adj kimitsugu. in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 19:08
L11	72	yamagata adj masahiro.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 19:08
L12	38	oshiba adj hisanori. in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 19:08
L13	15	sarumaru adj shogo. in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/05/09 19:08

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